1 Supplementary Information

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- 3 Intercalation of alkylamines in layered MoO₃ and *in-situ* carbonization for high-

4 performance asymmetric supercapacitor

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As seen from Fig. S3a and b, the raw MoO_3 presents the well-defined (010) crystal planes with a narrow interlayer spacing about 0.69 nm, showing the typical layered structure. After introduction of DA, the interlayer spacing of (010) crystal planes is significantly increased to ~2.65 nm, further demonstrating the successful intercalation of alkylamines (Fig. S3c and d). A final calcination of MoO_3/DA leads to the formation of sandwich-like MoO_3/C_{DA} hybrid nanostructures (Fig. S3e and f).



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Fig. S3 HRTEM images of MoO_3 (a, b), MoO_3/DA (c, d) and MoO_3/C_{DA} (e, f).

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10 According to the Eq.1 as following:

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where *i* is the current, *v* is the scan rate, and both *a* and *b* are the constant parameters, the *b* value can be determined as a slope of the linear plot between $\log i$ vs. $\log v$. Typically, the *b* value is equal to 1.0 for non-diffusion-controlled surface capacitive

(1)

15 and 0.5 for diffusion-controlled redox reaction.

As shown in Fig. S4a, the fitting results show that the *b* values in this work are 0.89 and 0.93 at the potentials of 0.08 and 0.49 V, respectively. It further confirms that the MoO₃/C_{DA} has both EDLC and surface redox reactions.

In addition, the contribution of the intercalation capacitance can be calculated basedon Eq. 2:

$$i(V) = k_1 v + k_2 v^{1/2} \tag{2}$$

 $i = av^b$

22 where k_1v and $k_2v^{1/2}$ correspond to the surface capacitive current and diffusion-

1 controlled current, respectively. By plotting $i/v^{0.5}$ vs. $v^{0.5}$, k_1 and k_2 can be determined 2 as the slope and intercept, respectively (Fig. S4b).

Fig. S4c shows the percentage of intercalation capacitive at different scan rates and it can be found that the intercalation capacitance decreases as the scan rate is increased due to the diffusion limit of the electrolytes.



Fig. S4 (a) log *i vs.* log *v*, (b) $i/v^{0.5}$ vs. $v^{0.5}$, and (c) a bar chart of the diffusion-8 controlled intercalation capacitance vs. scan rate of MoO₃/C_{DA}.



Fig. S5 (a) Cyclic voltammetry curves of $MoO_3/C_{DA}//EG$ asymmetric supercapacitor at increasing voltage window from 1.0 V to 1.6 V (all acquired at 100 mV·s⁻¹) and (b) Corresponding galvanostatic charge-discharge curves at a current density of 1.0 A·g⁻¹

14 from 1.0 V to 1.6 V.

tive peak area (%)	FWHM (eV)
24.2	1.6
233.1 4.3	
55.2	2.0
16.3	1.0
tive peak area (%)	FWHM (eV)
30.9	1.6
7.3	2.2
46.3	2.1
15.5	2.0
tive peak area (%)	FWHM (eV)
20.3	2.0
8.8	2.0
48.4	1.7
22.5	1.5
1	tive peak area (%) 24.2 4.3 55.2 16.3 tive peak area (%) 30.9 7.3 46.3 15.5 tive peak area (%) 20.3 8.8 48.4 22.5

Table S1 XPS peak fitting results for MoO_3/C_{PA} (a), MoO_3/C_{DA} (b) and MoO_3/C_{HDA} 2 (c) in the Mo 3d region.

Table S2 XPS peak fitting results for MoO_3/C_{PA} (a), MoO_3/C_{DA} (b) and MoO_3/C_{HDA} 5 (c) in the C 1s region.

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(a)	Peak	Position (eV)	Relative peak Area (%)	FWHM (eV)
Mo–C		283.3	18.7	1.0
С–Н		283.8	59.8	1.4
Intercalated C		285.3	21.5	1.9
(b)	Peak	Position (eV)	Relative peak Area (%)	FWHM (eV)
Мо-С		283.5	21.2	1.1
С–Н		284.4	49.0	1.1
Intercalated C		285.3	29.8	1.9
(c)	Peak	Position (eV)	Relative peak Area (%)	FWHM (eV)
	Мо-С	284.0	10.5	0.9
С–Н		284.5	61.3	1.2
Intercalated C		286.1	28.2	1.9

Table S3 A comparison of specific capacitance, rate capability and cycle stability of
 the present work with those reported MoO₃-based asymmetric supercapacitor.

ASC	Capacitance	Rate capability	Cycling performance	Ref	
	88 $F \cdot g^{-1}$	69.3%	86.5% (1 $A \cdot g^{-1}$ for	This	
$MOO_3/C_{DA}//LO$	$(1 \text{ A} \cdot \text{g}^{-1})$	$(1 \text{ to } 10 \text{ A} \cdot \text{g}^{-1})$	5000 cycles)	work	
$M_{0}O$ //AC	$68 \text{ F} \cdot \text{g}^{-1}$	20.7%	$113\% (2 \text{ A} \cdot \text{g}^{-1} \text{ for})$	1	
10003//AC	$(1 \text{ A} \cdot \text{g}^{-1})$	$(0.5 \text{ to } 10 \text{ A} \cdot \text{g}^{-1})$	10000 cycles)	-	
MoO ₃ –PPy//CNTs– 54 F·g ⁻¹	54 $F \cdot g^{-1}$	1	76% (5 $A \cdot g^{-1}$ for	2	
MnO_2	$(0.25 \text{ A} \cdot \text{g}^{-1})$	/	10000 cycles)		
WO _{3-x} /MoO _{3-x} //	216 mF·cm ⁻²	60.2% (2 to 20	75% (5 mA·cm ⁻²	3	
PANI/carbon	$(2 \text{ mA} \cdot \text{cm}^{-2})$	$A \cdot g^{-1} m A \cdot cm^{-2}$	for 10000 cycles)	5	
CE/MpO //CE/MaO	$4.86 \text{ mF} \cdot \text{cm}^{-2}$	65.8% (0.5 to 5	89% (5 mA·cm ⁻²	4	
$C\Gamma/WIIO_2//C\Gamma/WIOO_3$	$(0.5 \text{ mA} \cdot \text{cm}^{-2})$	mA·cm ^{−2})	for 3000 cycles)	·	
MnO ₂ @TiN//N-MoO _{3-x}	$10.3 \text{ mF} \cdot \text{cm}^{-1}$ (0.25 mA·cm ⁻¹)	/	80.3% (100 mV·s ⁻¹ for 5000 cycles)	5	
	(0.20		101 2 000 0 0 0 0 0 0 0 0 0 0 0 0 0 0 0		

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4 **Reference**

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